L Number	Hits		DB	Time stamp
1	27	pbo) same (boron adj oxide "B.sub.20.sub.3"	USPAT; US-PGPUB;	2004/10/13 10:44
		"B.sub.2 O.sub.3") and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same	EPO; JPO; DERWENT; IBM TDB	
2	27	(firing fired) ((313/582-587).CCLS.) and (lead adj oxide	USPAT;	2004/10/13 10:50
		pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated	US-PGPUB; EPO; JPO; DERWENT;	
3	11	sublayer sub adj layer lamina\$5) same (firing fired) ((313/582-587).CCLS.) and (lead adj oxide	IBM_TDB USPAT;	2004/10/13 12:15
		pbo) and powder same (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) same dielectric adj (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5)	US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2001, 20, 23
4	2	6160345.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 11:32
5	2	6160345.pn. and dielectric adj layer	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2004/10/13 11:33
			DERWENT; IBM_TDB	
6	1	6160345.pn. and dielectric adj layer same powder	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 11:34
7	1	6160345.pn. and dielectric adj layer and powder	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 11:36
8	2	6160345.pn. and dielectric adj layer same (bake baking baked)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 11:36
9	0	6160345.pn. and dielectric adj layer same (bake baking baked) same powder	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2004/10/13 11:37
			DERWENT; IBM_TDB	
10	1	6160345.pn. and dielectric adj layer same (bake baking baked) and powder\$5	USPAT; US-PGPUB; EPO; JPO;	2004/10/13 11:37
11	2	20040027071.did.	DERWENT; IBM_TDB USPAT;	2004/10/13 11:52
			US-PGPUB; EPO; JPO; DERWENT;	
12	2	20040027071.did. and pigment	IBM_TDB USPAT; US-PGPUB;	2004/10/13 11:58
			EPO; JPO; DERWENT; IBM_TDB	
13	61	calcium adj oxide near2 pigment	USPAT; US-PGPUB; EPO; JPO;	2004/10/13 12:00
			DERWENT; IBM TDB	

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14	0	((315/169.3).CCLS. (345/60).ccls.) and (lead adj oxide pbo) and powder same (coat\$5	USPAT; US-PGPUB;	2004/10/13 12:16
,		layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5) same (firing fired) same dielectric adj (coat\$5	EPO; JPO; DERWENT; IBM TDB	
		layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5)	_	
15	10	(((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 12:16
	:	O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2 O.sub.5"	IBM_TDB	
16	10	"Ta.sub.2 O.sub.5")) and (percent%6 "%") (((315/169.3).CCLS. (345/60).ccls.)) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/13 12:32
		(lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and (percent%6 "%")	_	
17	2		USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/13 12:32
18	2	6160345.pn.	IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2004/10/13 12:33
19	1	6160345.pn. and soften\$6	DERWENT; IBM_TDB USPAT;	2004/10/13 12:33
į			US-PGPUB; EPO; JPO; DERWENT; IBM TDB	
-	10	("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.	USPAT; US-PGPUB	2004/10/12 16:22
-	209	glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide	USPAT; US-PGPUB	2004/10/12 13:38
		dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide		
,		"La.sub.20.sub.3" "La.sub.20.sub.3") and (tantalum adj oxide "Ta.sub.20.sub.5" Ta.sub.20.sub.5"		
-	212	glass.ab,ti,clm. and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/12 13:38
		O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and	10:1_108	
		(tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")		

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-	147	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3"	USPAT; US-PGPUB;	2004/10/12 13:39
		"B.sub.2 O.sub.3") same (silicon adj (oxide	EPO; JPO;	
		dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti	DERWENT; IBM TDB	
		O.sub.2") and (zirconium adj oxide	_	
		"ZrO.sub.2") and (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") and		}
		(tantalum adj oxide "Ta.sub.20.sub.5"		
	-	"Ta.sub.2 O.sub.5")		2004/20/20 22 20
-	77	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3"	USPAT; US-PGPUB;	2004/10/12 13:39
		"B.sub.2 O.sub.3") same (silicon adj (oxide	EPO; JPO;	
		dioxide) glass "SiO.sub.2" "Si O.sub.2")	DERWENT;	
		same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide	IBM_TDB	
		"ZrO.sub.2") same (lanthanum adj oxide		
		"La.sub.20.sub.3" "La.sub.2 0.sub.3") same (tantalum adj oxide "Ta.sub.20.sub.5"		
		"Ta.sub.2 O.sub.5")		
-	72		USPAT;	2004/10/12 13:40
		same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide	US-PGPUB; EPO; JPO;	
	ŀ	dioxide) glass "SiO.sub.2" "Si O.sub.2")	DERWENT;	
	İ	same (titanium adj oxide "TiO.sub.2" "Ti	IBM_TDB	
		O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide		
		"La.sub.20.sub.3" "La.sub.2 0.sub.3") same		
		(tantalum adj oxide "Ta.sub.20.sub.5" "Ta.sub.2 0.sub.5") and (percent "%")		
_	72	l	USPAT;	2004/10/12 13:40
		same (boron adj oxide "B.sub.20.sub.3"	US-PGPUB;	
		"B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2")	EPO; JPO; DERWENT;	
		same (titanium adj oxide "TiO.sub.2" "Ti	IBM_TDB	
		O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide		
		"La.sub.20.sub.3" "La.sub.2 O.sub.3") same		
		(tantalum adj (pentoxide oxide)		
		"Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%")		
-	40	glass.ab,ti,clm. and (lead adj oxide PbO)	USPAT;	2004/10/12 13:43
	İ	same (boron adj oxide "B.sub.20.sub.3"	US-PGPUB;	
		"B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2")	EPO; JPO; DERWENT;	,
		same (titanium adj oxide "TiO.sub.2" "Ti	IBM_TDB	
		O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide		
		"La.sub.20.sub.3" "La.sub.2 O.sub.3") same		
		(tantalum adj (pentoxide oxide)		
		"Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%")		
-	9	glass.ab,ti,clm. and (lead adj oxide PbO)	USPAT;	2004/10/12 13:44
		same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide	US-PGPUB; EPO; JPO;	
		dioxide) glass "SiO.sub.2" "Si O.sub.2")	DERWENT;	
		same (titanium adj oxide "TiO.sub.2" "Ti	IBM_TDB	
-		O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide		
		"La.sub.20.sub.3" "La.sub.2 0.sub.3") same		
		(tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 0.sub.5") same		
		(percent "%") and softening adj point		

-	6	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") same (zirconium adj oxide "ZrO.sub.2") same (lanthanum adj oxide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:50
		"La.sub.20.sub.3" "La.sub.2 O.sub.3") same (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") same (percent "%") and plasma		
-		"20040180773"	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 13:57
-	1	20040180773.did.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/12 13:57
-		(("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 0.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 0.sub.3") and (tantalum adj	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:17
	0	(pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5") and (percent "%") (("6617789" "6497962" "6419540" "6160345" "6376400" "6355586" "5948537" "5714840").pn. ("20020034917" "20020036466").did.) and (lead adj oxide PbO) and (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:22
_	228	"Ta.sub.2 O.sub.5") (fujimine near2 satoshi manabe near2 tsuneo).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/12 14:18
-	28	((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/12 14:40
-	1	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and (lead adj oxide pbo) and (boron adj (trioxide oxide) "B.sub.20.sub.3" "B.sub.2 0.sub.3") and (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") and (titanium adj oxide "TiO.sub.2" "Ti O.sub.2") and (zirconium adj oxide "ZrO.sub.2") and (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 0.sub.3") and (tantalum adj (pentoxide oxide) "Ta.sub.2 0.sub.5" "Ta.sub.2 0.sub.5")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:38

-	1	20040027071.did. and "TiO.sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 14:38
-	8	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+"	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 14:41
-	3	(((fujimine near2 satoshi manabe near2 tsuneo).in.) and glass near2 powder and (lead adj oxide pbo)) and "+".clm.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 14:41
-	57	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:51
-	57	•	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 14:52
	8	glass.ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide Cuo) and (saphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:06
_	2 9	(silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") and plasma and (copper adj oxide Cuo) and (saphire sapphire aluminum adj oxide "al.sub.2O.sub.3" "al.sub.2 O.sub.3") and (barium adj oxide bao)	USPAT; USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:05 2004/10/12 15:07

	52	(silicon adj (oxide dioxide) glass	USPAT;	2004/10/12 15:10
	32	"SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm.	US-PGPUB;	2001, 10, 12 23:10
		and (lead adj oxide PbO) same (boron adj	EPO; JPO;	
		oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3")	DERWENT;	
			1	
		same (silicon adj (oxide dioxide) glass	IBM_TDB	
		"SiO.sub.2" "Si O.sub.2" silica) same		
		((titanium adj oxide "TiO.sub.2" "Ti		
		O.sub.2") (zirconium adj oxide "ZrO.sub.2")		
		(lanthanum adj oxide "La.sub.20.sub.3"		
		"La.sub.2 O.sub.3") (tantalum adj		
		(pentoxide oxide) "Ta.sub.20.sub.5"		
		"Ta.sub.2 O.sub.5")) same (percent "%") and		
		plasma and ((copper adj oxide Cuo) (
		(saphire sapphire aluminum adj oxide		
		"al.sub.20.sub.3" "al.sub.2 0.sub.3") and		
		(barium adj oxide bao)))		0001/00/00 05 05
-	15	(silicon adj (oxide dioxide) glass	USPAT;	2004/10/12 15:36
	}	"SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm.	US-PGPUB;	
		and (lead adj oxide PbO) same (boron adj	EPO; JPO;	
		oxide "B.sub.20.sub.3" "B.sub.2 0.sub.3")	DERWENT;	
	i	same (silicon adj (oxide dioxide) glass	IBM TDB	
		"SiO.sub.2" "Si O.sub.2" silica) same	_	
		((titanium adj oxide "TiO.sub.2" "Ti		
		O.sub.2") (zirconium adj oxide "ZrO.sub.2")		1
	,	(lanthanum adj oxide "La.sub.20.sub.3"		
		"La.sub.2 O.sub.3") (tantalum adj		
		(pentoxide oxide) "Ta.sub.20.sub.5"		
	1	"Ta.sub.2 O.sub.5")) same (percent "%") same		
	1	((copper adj oxide Cuo) ((saphire sapphire		
	İ	aluminum adj oxide "al.sub.20.sub.3"		
		"al.sub.2 O.sub.3") and (barium adj oxide		
		bao))) and plasma		
_	199	(silicon adj (oxide dioxide) glass	USPAT;	2004/10/12 15:37
		"SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm.	US-PGPUB;	,,
		and (lead adj oxide PbO) same (boron adj	EPO; JPO;	
		oxide "B.sub.20.sub.3" "B.sub.2 0.sub.3")	DERWENT;	
		same (silicon adj (oxide dioxide) glass	1	
			IBM_TDB	,
		"SiO.sub.2" "Si O.sub.2" silica) same	1	
		((titanium adj oxide "TiO.sub.2" "Ti		
		O.sub.2") (zirconium adj oxide "ZrO.sub.2")	1	
		(lanthanum adj oxide "La.sub.20.sub.3"		
		"La.sub.2 O.sub.3") (tantalum adj	ì	
		(pentoxide oxide) "Ta.sub.20.sub.5"		
	'	"Ta.sub.2 O.sub.5")) same (percent "%") same		
	ļ	((copper adj oxide Cuo) ((saphire sapphire	1	
		aluminum adj oxide "al.sub.20.sub.3"	1	l.
		"al.sub.2 O.sub.3") and (barium adj oxide	1	
				Į.
		bao)))		
		(silicon adj (oxide dioxide) glass	USPAT;	2004/10/12 15:40
-	4		I IIC DONIED.	
-	4	"SiO.sub.2" "Si O.sub.2" silica).ab,ti,clm.	US-PGPUB;	
- , ;	4	and (lead adj oxide PbO) same (boron adj	EPO; JPO;	
- '	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3")		
- ·	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3")	EPO; JPO; DERWENT;	
- '	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass	EPO; JPO;	
,	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2")	EPO; JPO; DERWENT;	
·	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3"	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj	EPO; JPO; DERWENT;	·
,	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5"	EPO; JPO; DERWENT;	
-	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5"	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same	EPO; JPO; DERWENT;	
	4	and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire	EPO; JPO; DERWENT;	

. *				
-	8	(plasma adj display adj panel pdp).ab,ti,clm. and (lead adj oxide PbO) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") same (silicon adj (oxide dioxide) glass "SiO.sub.2" "Si O.sub.2" silica) same ((titanium adj oxide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 15:53
		"TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide)		·
		"Ta.sub.20.sub.5" "Ta.sub.2 0.sub.5")) same (percent "%") same ((copper adj oxide Cuo) ((saphire sapphire aluminum adj oxide "al.sub.20.sub.3" "al.sub.2 0.sub.3") and (barium adj oxide bao))) and softening adj	ŕ	
-	2	point 20020096666.did.	USPAT; US-PGPUB; EPO; JPO;	2004/10/12 16:38
_	1	6238847.pn. and barium	DERWENT; IBM_TDB USPAT;	2004/10/12 16:23
-	1	6238847.pn. and (barium BaO)	US-PGPUB USPAT;	2004/10/12 16:27
-	0	6238847.pn. and softening	US-PGPUB USPAT; US-PGPUB	2004/10/12 16:27
-	1	6238847.pn.	USPAT; US-PGPUB	2004/10/12 16:36
-	1	20020096666.did. and electrode	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 16:42
-	487	(313/586).CCLS.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 16:42
-	113	((313/586).CCLS.) and (lead adj oxide pbo)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/10/12 16:42
-	. 53	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3")	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/10/12 16:43
-	18	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.20.sub.3" "B.sub.2 O.sub.3") and ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.20.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:45
-	. 5	((313/586).CCLS.) and (lead adj oxide pbo) same (boron adj oxide "B.sub.2O.sub.3" "B.sub.2 O.sub.3") same ((titanium adj oxide "TiO.sub.2" "Ti O.sub.2") (zirconium adj oxide "ZrO.sub.2") (lanthanum adj oxide "La.sub.2O.sub.3" "La.sub.2 O.sub.3") (tantalum adj (pentoxide oxide) "Ta.sub.2O.sub.5" "Ta.sub.2 O.sub.5"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/12 16:44

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7-	15		USPAT;	2004/10/12 22:30
		same (boron adj oxide "B.sub.20.sub.3"	US-PGPUB;	
		"B.sub.2 O.sub.3") and ((titanium adj oxide	EPO; JPO;	
		"TiO.sub.2" "Ti O.sub.2") (zirconium adj	DERWENT;	
		oxide "ZrO.sub.2") (lanthanum adj oxide	IBM_TDB	!
		"La.sub.20.sub.3" "La.sub.2 O.sub.3")		
		(tantalum adj (pentoxide oxide)		
		"Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and		
		(percent%6 "%")		
-	2	20010024582.did.	USPAT;	2004/10/12 16:59
	ŧ		US-PGPUB;	
	•		EPO; JPO;	
			DERWENT;	1
			IBM_TDB	
-	1	20010024582.did. and softening adj point	USPAT;	2004/10/12 16:59
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	1
			IBM TDB	
-	1	20010024582.did.	USPAT;	2004/10/12 22:03
			US-PGPUB]
-	1	20010024582.did. and BaO	USPAT;	2004/10/12 22:05
			US-PGPUB	
-	1	20010024582.did. and BaO same PbO	USPAT;	2004/10/12 22:16
			US-PGPUB	}
-	1	20010024582.did. and softening adj point	USPAT;	2004/10/12 22:16
			US-PGPUB	į l
-	2	20040027071.did.	USPAT;	2004/10/13 11:52
	1		US-PGPUB;	
			EPO; JPO;	
			DERWENT;	Į l
			IBM TDB	1
-	38	((313/582-587).CCLS.) and (lead adj oxide	USPAT;	2004/10/13 12:16
		pbo) same (boron adj oxide "B.sub.20.sub.3"	US-PGPUB;	
		"B.sub.2 O.sub.3") and ((titanium adj oxide	EPO; JPO;	
		"TiO.sub.2" "Ti O.sub.2") (zirconium adj	DERWENT;	
		oxide "ZrO.sub.2") (lanthanum adj oxide	IBM_TDB	
		"La.sub.20.sub.3" "La.sub.2 0.sub.3")	-	
		(tantalum adj (pentoxide oxide)		
		"Ta.sub.20.sub.5" "Ta.sub.2 O.sub.5")) and		
		(percent%6 "%")		1
_	1		USPAT;	2004/10/12 22:46
		-	US-PGPUB	' '